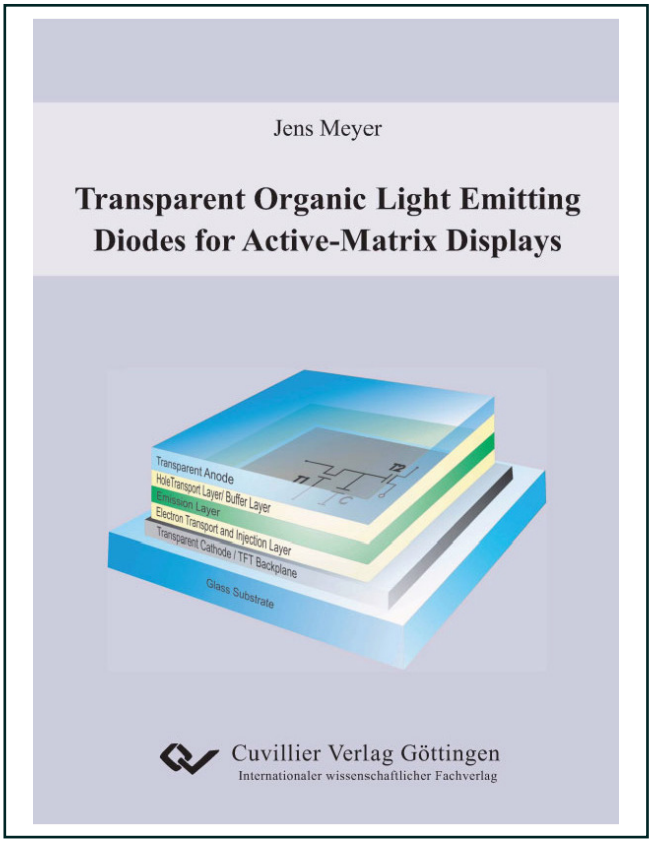
Jens Meyer (Autor)

Transparent Organic Light Emitting Diodes for Active-Matrix Displays



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